

01 AUG 1 6 2004 PATENTS & TRADEMARK OFFICE	U.S. Department of Commerce Patent and Trademark Office LIST OF PRIOR ART CITED BY APPLICANT (Use Several Sheets If Necessary)	Atty. Docket No. CH-7929/LeA 38,206	Serial No. 10/668,424
	Applicant Frank Berendes et al		
	Filing Date September 24, 2003	Group	

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
NL	AA	6,515,134	02/04/03	Bel. to corresp. to EP Amano et al	1 153 919 546	315	
NL	AB	2003/0130521	07/10/03	Bel. to corresp. to EP Amano et al	1 153 919 546	290	
NL	AC	6,642,387	11/04/03	Bel. to corresp. to EP Amano et al	1 153 919 546	314	
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							Yes	No*
NL	AL	03 078418	09/25/03	World (Abstract Attached)				
	AM							
	AN							
	AO							
	AP							

OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)

NL	AR	FOGAGNOLO M ET AL: "Homochiral (R)- and (S)-1-heteroaryl- and 1-aryl-2-propanols via microbial redox" TETRAHEDRON ASYMMETRY, ELSEVIER SCIENCE PUBLISHERS, AMSTERDAM, NL, Bd. 9, Nr. 13, 3. Juli 1998 (1998-07-03), Seiten 2317-2327, XP004131378 ISSN: 0957-4166 "Tabelle 2"
NL		FURUICHI A ET AL: "THE USE OF MICROORGANISMS IN ORGANIC SYNTHESIS 5."
NL	AS	MICROBIOLOGICAL ASYMMETRIC REDUCTION OF METHYL-2-METHYL-3-2-THIENYL-3-OXO PROPIONATE" CHEMICAL AND PHARMACEUTICAL BULLETIN (TOKYO), Bd. 32, Nr. 4, 1984, Seiten 1619-1623, XP001179422 ISSN: 0009-2363 "Abbildung 1"
NL		QUIROS M ET AL: "Enantioselective reduction of beta-keto amides by the fungus Mortierella isabellina" TETRAHEDRON: ASYMMETRY, ELSEVIER SCIENCE PUBLISHERS, AMSTERDAM, NL, Bd. 8, Nr. 18, 25. September 1997 (1997-09-25), Seiten 3035-3038, XP004090508 ISSN: 0957-4166 "Zusammenfassung" Tabelle 1, Produkt 2a-c
NL	AT	EXAMINER <u>Rehman Patel</u>
		DATE CONSIDERED 09-26-2005

EXAMINER Initial if references considered, whether or not citation is in conformance with MPEP 609: Draw line through if not in conformance and not considered. Include copy of this form with next communication to applicant.

Neither English Language Equivalent nor an English Language Translation is available.